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(71) Applicant: TAIWAN SEMICONDUCTOR MANUFACTURING COMPANY

LTD., HSINCHU (TW)

(72) Inventors: CHUN-WEI CHANG, TAOYUAN COUNTY (TW); JIAN-HONG LIN, YUNLIN (TW); SHU-YUAN KU,

NEW TAIPEI CITY (TW); WEI-CHENG LIU, HSINCHU COUNTY (TW); YINLUNG LU, HSINCHU (TW); JUN HE, HSINCHU COUNTY (TW)

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(57)ABSTRACT

A package component includes a first substrate and a first conductive layer. The first substrate has a first surface and a second surface opposite to the first surface. The first conductive layer is disposed over the first surface of the first substrate. The first conductive layer includes a first conductive feature and a second conductive feature over the first conductive feature. The second conductive features covers a portion of the first conductive feature. A resistance of the second conductive feature is lower than a resistance of the second conductive feature. The first substrate includes a single-sided or a double-sided copper-clad laminate.



Providing or receiving a core substrate

Forming a first patterned conductive film over the core substrate

Selectively depositing a second conductive film over the first patterned conductive film to form a conductive layer comprising the first patterned conductive film and the second conductive film, wherein a resistance of the second conductive film is lower than a resistance of the first patterned conductive film

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